Electronic Supplementary Information (ESI)

Efficient FAPbI₃-PbS quantum dot graphene -based phototransistors

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Fig.S1. Schematic illustration of ligand exchange process.



Fig.S2. Wetting angle measurement of a) LPE (102^{\Box}) and b) GP (43^{\Box}) samples on graphene.



Fig.S3. High resolution TEM images showing QDs. a) SPE with marked paralleled-fringe areas. b) LPE without signs of inter-dot fusion.



Fig.S4. Absorption spectra of CQD films on Graphene/Si/SiO₂ substrate.



Fig.S5. I-V curves of GP, LPE and SPE phototransistors a) in dark condition and under white illumination at V_G = 0V and b) under white illumination at various gate voltages. c) I-t characteristics of all three devices under white illumination and V_{SD} =-1 V and d) the absorption spectrum of PbS QDs.

Table.S1. Figures of merit for the graphene-based phototransistors examined under white illumination at $V_{SD} = 20$ V.

Device	R(A/W)	J _d (A/cm ²)	D*(Jones)
GP	0.002	0.004	5*10 ⁷
SPE	0.004	0.006	108
LPE	0.003	0.005	7*10 ⁷



Fig.S6. Air stability results of the devices.

Photoresponse(µA)in day					
	1 st	7 th	14 th	21 th	28 th
Device name					
GP	0.02	0.02	0.02	0.02	0.02
LPE	0.21	0.20	0.19	0.16	0.15
SPE	1.8	1.8	1.76	1.69	1.66

Table.S2. The air stability results of all devices for 28 days.



Fig.S7. Transfer characteristics of GP, LPE and SPE samples under IR illumination at V_{SD} = 1V.

Ref.	V _g (V)	Light power (mW)	I_{LIGHT}/I_{DARK}
PbS-OA/G [A]	30-60	30pW	1.4
PbS/G [B]	-20-80	0.00068mW	1.1
PbS-EDT/G [C]	-40-60	267pW	2
G/PbS-EDT/G [D]	20	0.86µW	13
PbS-FAPbI ₃ /G	-1	110mW	34
[this work]			

Table.S3. Performance of PbS QDs/graphene phototransistors.

Table.S4. Fitted data values from the Nyquest polts according to the equvalent circuit.

Sample	$R_s(\Omega)$	C ₁ (µF)	$R_1(\Omega)$
GP	44	0.9	14230
LPE	18	0.5	1260
SPE	20	5.3	94

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